

Condensation and Evaporation of Mutually Repelling Particles :Steady states and limit cycles

Tapati Dutta¹, Nikolai Lebovka² and S. Tarafdar³

¹ Physics Department, St. Xavier's College,
Kolkata 700016, India

²F. D. Ovcharenko Biocolloid Chemistry Institute
42, Vernadsky Av., Kyiv, Ukraine

³ Condensed Matter Physics Research Centre,
Physics Department, Jadavpur University,
Kolkata 700032, India.

Email: sujata@juphys.ernet.in (S Tarafdar)

Abstract

We study condensation and evaporation of particles which repel each other, using a simple set of rules on a square lattice. Different results are obtained for a mobile and an immobile surface layer. A two point limit cycle is observed for high temperature and low pressure in both cases. Here the coverage oscillates between a high and a low value without ever reaching a steady state. The results for the immobile case depend in addition on the initial coverage.

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1 Introduction

Recently computer simulations on cellular automata type models [1, 2, 3] have been suggested which can be applied to simulate the development of a surface layer under different physical conditions. A randomly occupied square lattice is taken and particles are allowed to stick at vacant sites or evaporate from occupied sites according to a prescribed set of rules. Appropriate probabilities for the 'growing' and 'culling' are set according to temperature and pressure conditions required. We can also introduce an effective interaction between the particles by making the probabilities a function of the surroundings of a site, e.g. the number of nearest neighbours.

In our earlier work [1] we started with a randomly occupied square lattice and let particles evaporate with a probability which decreased with the number of occupied neighbouring sites. This amounted to an attractive interaction between the particles. The condensation was a function of only the superincumbent pressure. The present paper is an extension of the earlier

work, here we introduce an effective repulsive interaction between particles, by allowing the condensation probability at an empty site to decrease with the number of occupied neighbours. The evaporation probability is a function of temperature only. The results are very interesting. We study as in the previous work [1] evolution of a mobile layer by analytical and numerical methods and an immobile layer by computer simulation. In both cases we find a steady final coverage under some conditions, but a two-point limit cycle showing oscillations in the coverage when temperature is high and pressure low.

In the next section we describe the model. The results are presented in the third section and discussion and conclusions in the last.

2 The Model

The process of condensation/evaporation or adsorption/desorption is described traditionally by two different sets of models – one for a mobile adsorption layer and one for an immobile layer[4, 5]. Probabilities for sticking and evaporation on a two-dimensional monolayer are specified according to the physics behind the model. These are functions of the temperature, superincumbent pressure and the existing coverage. At equilibrium, the sticking and evaporation probabilities are set equal and the resulting equation is solved to get the equilibrium coverage at that temperature and pressure.

The simplest mobile layer model is a two-dimensional ideal gas, and the improved versions include interaction between particles, similar to a two-dimensional Van der Waal gas. The so-called immobile layer models introduce a sticking probability, depending on how long a molecule in the vapor above the surface is in contact with a surface site. The simplest ‘immobile model’ is the Langmuir equation derived as follows.

For vapor condensation the particle flux, i.e. the number of particles deposited per unit time per unit surface area is equal to:

$$c = \frac{P\lambda}{h} \quad (1)$$

where P is the pressure,

$$\lambda = \sqrt{h^2/(2\pi mkT)}$$

is de Broglie length, h is Planck constant. The probability of condensation per unit time is obtained by dividing c by the total number of sites available for condensation. And the same may be done for the evaporation probability. Flux of evaporation from saturated surface (at $p = 1$) may be approximated by [6] :

$$d = \frac{kT}{h\lambda^2} \exp(-E_e/kT) \quad (2)$$

Condensation probability is set equal to evaporation probability, giving equilibrium:

$$\frac{P\lambda^3}{kT}(1-p) = \exp(-E_e/kT)p \quad (3)$$

and we have the simple Langmuir equation

$$Pb = \frac{p}{1-p} \quad (4)$$

where

$$b = \frac{\lambda^3}{kT} \exp(E_e/kT),$$

E_e is activation energy for evaporation.

In this approximation it is assumed that evaporation energy is the same for all configurations.

In the present work we introduce a repulsive interaction between particles, as follows - condensing particles are less likely to stick at sites surrounded by more neighbors. This mimics a situation where the adsorbing particle has to overcome the potential barrier due the repelling neighbors to reach a vacant site on the substrate. It is implied that the substrate attracts the adsorbing particle.

We define a probability for condensation on a vacant site f_c determined by the pressure as

$$f_c = P/P_s \quad (5)$$

where P_s is a saturation pressure and $0 < f_c < 1$. The growth probability at a vacant site with n occupied neighbors is proportional to f_c^n . We have

$$P_{gr} = (1-p)^5 f_c^4 + 4(1-p)^4 p f_c^3 + 6(1-p)^3 p^2 f_c^2 + 4(1-p)^2 p^3 f_c + (1-p)p^4 \quad (6)$$

The successive terms in the RHS above represent the probability of a vacant site having respectively 4,3,2,1 and 0 vacant near neighbor sites. P_{gr} can be written in the compact form

$$P_{gr} = (1-p)(p f_c + 1 - p)^4 \quad (7)$$

The culling probability is assumed to be a function of temperature only

$$P_{cull} = p(kT/P_s\lambda^3)\exp(-E_e/kT) \quad (8)$$

P_s is temperature dependent, and this must be taken into account. But we can approximate it by the simple relation that follows from equilibrium relation on the surface of fluid

$$P_s = \frac{kT}{\lambda^3} \exp(-E_{vap}/kT) \quad (9)$$

where E_{vap} is the enthalpy of vaporization of a fluid that supports vapour.

In this formulation the simplest condensation evaporation equilibrium condition is

$$\frac{P}{P_s}(1 - p) = \frac{kT}{P_s \lambda^3} \exp(-E_e/kT)p = \exp -\Delta E/kTp \quad (10)$$

where $\Delta E = E_e - E_{vap}$

Here too condensation probability f_c (or reduced pressure P^*) is

$$f_c = P/P_s \quad (11)$$

and the evaporation probability is

$$f_e = \exp(-\Delta E/kT) \quad (12)$$

That means that the molecules evaporate from the our surface with probability 1 when $E_e = E_{vap}$, when energy of evaporation from surface E_e equals to energy of evaporation from surface of liquid that support vapor E_{vap} .

So, we can rewrite P_{cull} as

$$P_{cull} = p \exp(-1/T^*) \quad (13)$$

where $f_c = P/P_s$ and $T^* = kT/\Delta E$

Our model is complementary to the Fowler-Guggenheim model [4, 5], where the condensation probability is dependent only on pressure, but the evaporation probability decreases with the number of occupied near neighbors. The neighbors are assumed to attract the particle and create a barrier to evaporation. This type of interaction was incorporated in Dutta et al [1].

Now we study the behavior of this system for different values of the temperature and pressure parameters. We look at the two different situations the mobile surface layer and the immobile layer.

2.1 Mobile surface layer

Let us suppose that the energy barrier for motion of the deposited particles along the surface is very low so a continuous rearrangement is going on. In this case the distribution of particles always becomes random and the probabilities in eq(6) are always valid. So one can equate the growth and culling probabilities in the steady state and solve for the coverage p . We confine ourselves to ranges of T^* and P^* , which give growth and culling probabilities in the range 0 – 1. We find that meaningful positive values for the coverage between 0 and 1 are obtained for a very narrow range of temperature and pressure. The results are shown in the next section. We may also see the how the coverage evolves using the following iterative procedure

$$p_f = p_i + P_{gr} - P_{cl} \quad (14)$$

and

$$p_i = p_f \quad (15)$$

here p_i is the initial coverage and p_f the final. If there is a steady solution the final coverage p_f converges to a steady value. We find however that in some combinations of the pressure and temperature parameters the coverage converges to a stable limit cycle, oscillating between two positive and realistic values. The solution for p in eq.(6) now becomes an unstable fixed point. This is very interesting and reminiscent of the discovery of oscillatory behaviour in real chemical systems [7, 8, 9].

The results obtained here can be verified from a computer simulation on a finite system. This was done as follows.

In the mobile case, the adsorbed molecules can move laterally on the surface. The physical situation simulated is described by eq.(6) . A two-dimensional square lattice of unit spacing and size 300×300 , is occupied randomly with an initial coverage $p_{initial}$. Every occupied site is assigned the value 1, empty sites are assigned the value 0. The occupied sites are then culled parallally with a probability which is the same for each occupied site

$$g = \exp(-1/T^*)$$

. For very large T^* the culling probability approaches 1. The vacant sites are filled with a probability dependent on the number of vacant near neighbor sites n as f_c^n . After one round of growth and culling is complete, the concentration of the occupied sites p_{final} is calculated.

In the next time-step, the p_{final} of the previous time-step becomes the new $p_{initial}$. The square lattice is then randomly occupied afresh with this $p_{initial}$. A complete time-step begins with the random occupation of all sites with a $p_{initial}$ and ends with the assignment of the p_{final} to the $p_{initial}$ of the next time-step. This iterative process stops when p_{final} saturates with increasing time to a definite value. In the simulation, we checked up to 50,000 time-steps. The ‘mobility’ of the molecules is simulated by the randomization of the concentration $p_{initial}$ in the beginning of every time-step.

2.2 Immobile Surface Layer

If we consider the energy barrier to surface movement of the particles to be large enough the arguments presented in the last subsection are not valid. We start with a certain concentration of particles randomly distributed on a square lattice and allow growing and culling according to our rules. But after one time-step the distribution is no longer random, so we cannot find out the number of new growth or evaporation sites as in eq.(6). We can however simulate the system as above without the randomization procedure after each round of growth and culling. This mimics the development of a surface layer where the particles are not free to move laterally on the surface. The results in this case are quite different .

3 Results

We present the results for the mobile and immobile layer case. The mobile layer results are done analytically or by numerical iteration and verified by computer simulation. The immobile layer results are done by computer simulation as calculation is not possible here.

3.1 Results for the mobile layer

The results are shown in figure 1. The final coverage p for each P^* , on increasing T^* , from a low value shows a bifurcation at a certain point to a two state limit cycle. The temperature and coverage at this point are denoted respectively by T_b^* and p_b , the inset shows the variation of T_b^* and p_b with P^* .

These results are independent of the initial coverage. For T^* very large and $P=1$ there is an oscillation between $p_{initial}$ and $1 - p_{initial}$, as is also evident from eq.(6).

3.2 Results for the immobile surface layer

The immobile situation can be studied only by computer simulation. Starting with an initial random distribution of particles the system is allowed to evolve and the final coverage for different P and T^* is studied. In this case as there is no randomization, the system takes a very long time to reach the steady state, and we have observed up to 30,000 time steps. Steady state solutions of p_{final} are obtained for $P_{cull} < 1$. The steady state isobars and isotherms are shown in Fig.2. and Fig.3. respectively. At $P_{cull}=1.0$, oscillations between a two-point limit sets in for all values of P . However for every P , there is a certain initial coverage, p_α that yields a final coverage oscillating in a narrower confine between 0.4 and 0.5 for all P . Even a departure of 0.05 from p_α , shifts the final coverage to the fixed point limits of the wider limit cycle. The rate of convergence to p_{final} from different $p_{initial}$ s other than p_α , is slower for higher values of P . For $p_{initial}$ very close to p_α in the case of $P = 0.9$, we checked for 50,000 time steps to detect whether the final coverage was approaching the fixed points of the wider limit cycle. The p_α increases slowly with P as displayed in Table.I.

4 Discussion

We have demonstrated that the condensation/evaporation problem seen as a modification of the percolation problem on a square lattice shows very interesting possibilities. There is firstly, the question of mobile and immobile layer models of chemical physics [4]. From our point of view equating the growth and culling probabilities to find the steady state coverage is valid only when the particles can rearrange very fast to preserve the random distribution. And we demonstrate that making the particles truly immobile, on the two-dimensional surface gives a

quite different final coverage. This is also dependent on the initial coverage. This was discussed in the previous work [1] with an attractive interaction between particles. Careful experiments are needed to test the justification of these arguments.

The most striking result of this work is the observation of oscillations in the condensation/evaporation problem, using such an extremely simple model, without taking any details of the system into account. Earlier well known work on non-linear mathematical equations [7] show the appearance of bifurcations, repeated period doubling sometimes leading to chaos. And such situations are found in real life in problems of physics, chemistry and biology. Chemical systems are known to exhibit oscillations in concentration of reactants and products in chemical reactions [8, 9]. There is also some study of such a phenomenon in condensation/evaporation problems [10, 11]. Experiments with repelling particles adsorbing on a substrate are reported [12], but in this experiment two different types of particles are involved.

One possibility of having a repulsive interaction is with similarly charged particles condensing on an oppositely charged substrate.

So in conclusion the simple stochastic model with growth and evaporation on a square lattice gives rise to a host of interesting phenomena. With an attractive interaction between particles phase transitions and hysteresis was observed [1], While a repulsive interaction gives oscillations in coverage under certain conditions.

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P	0.1	0.2	0.3	0.5	0.6	0.7	0.8	0.9
p_α	0.23	0.25	0.265	0.305	0.33	0.35	0.39	0.43

Table I : The variation of p_α with P

Figure captions:

Figure 1 : Isobars for the final coverage for the mobile layer. At T^*_b , the steady solution for p_b shows the bifurcation to a limit cycle. The inset shows variation of T^*_b and p_b with P^* .

Figure 2 : Isobars for the immobile case showing variation of coverage with $\exp(-1/T^*)$. The values of P for each curve are shown in the figure.

Figure 3 : Isotherms for the immobile case showing variation of coverage with pressure P . Stable p are obtained for $\exp(-1/T^*)$ upto 0.9, for $\exp(-1/T^*)=1.0$ oscillations are obtained.





